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Supporting Information

Antimony trifluoride incorporated SnO₂ for high-efficiency planar perovskite solar cells

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Experimental Section

Materials:

The SnO₂ colloid precursor was purchased from Alfa Aesar. N, N-dimethylformamide (DMF), dimethyl sulfoxide (DMSO) and chlorobenzene were purchased from Sigma-Aldrich. PbI₂, FAI, MABr, MAcl, bis(trifluoromethane) sulfonimide lithium salt (Li-TFSI), 4-tertbutylpyridine (TBP) and Spiro-OMeTAD were purchased from Xian Polymer Light Technology Corp. Antimony fluoride (SbF₃) was purchased from Aladdin.

Solar cells Fabrication:

The ITO glass substrate (1.78×1.78 cm) was cleaned with deionized water, acetone and isopropanol respectively for 15 minutes. Then the clean substrate was dried by a nitrogen stream, and treated with oxygen plasma for 5 minutes. The SnO₂ colloidal precursor was diluted with ultrapure water (volume ratio 1.2:6.5) to prepare the SnO₂ precursor (marked by SnO₂). SnO₂ precursors with different SbF₃ concentrations (0.2mg/mL, 0.4mg/mL and 0.6mg/mL) were also prepared (marked by SnO₂-SbF₃). The SnO₂ precursors without/with different SbF₃ concentrations were spin-coated on the ITO substrates at a speed of 3000 rpm for 35 s, and then annealed at 150°C for 30 minutes in the air (relative humidity RH=40%). SnO₂ film and SnO₂-SbF₃ film were consequently obtained. Then the substrate was transferred to a nitrogen glove box to prepare the perovskite film. The perovskite film was prepared by a two-step method. First, 760 mg PbI₂ and 18.2 mg CsI were dissolved in a mixed solvent of DMF (1 mL) and DMSO (160 μL), and then stirred at 60 °C for 15 h. The PbI₂ solution was filtered through a 0.22 μm pore PTFE filter, and then PbI₂ solution was spin-coated on the ETL/ITO substrate at a speed of 1600rpm for 20s and 4000rpm for 30s, respectively. Then the PbI₂ film was annealed at 70°C for 2 minutes. Second, 120 μL of mixed ammonium salt isopropanol solution (110 mg FAI, 11.5 mg MACl and 11 mg MABr dissolved in 1500 μL isopropanol) was spin-coated on the PbI₂ film at a speed of 2000 rpm for 23 s, the perovskite layer was obtained. The perovskite film was then taken out of the glove box and annealed at 140°C for 20 minutes in the air (RH =40%). After annealing, 120 μL isopropanol was used to clean the excess ammonium salt in the perovskite film. Spiro-OMeTAD solution was subsequently spin-coated on the perovskite layer at 4000 rpm for 30 s. After that, the prepared film was placed into a desiccator for 20 hours. Finally, 90 nm Au film was deposited as electrode by thermal evaporation.

Characterization:

XPS was measured by XPS machine (ESCALAB250XI, Thermo Fisher Scientific). The X-ray diffraction patterns were measured by using a Rigaku-2500 X-ray diffractometer with an X-ray tube (Cu K α , λ =1.5406 Å). UPS was measured by UPS machine (AXIS ULTRA DLD, Kratos). The UV light source is He I, and the energy of He I is 21.22 eV. The basic

vacuum of the Analytical Chamber is 3.0×10^{-8} Torr, and the bias voltage is -9 V. The top-view and cross-sectional SEM images were attained using a scanning electron microscope (SEM, HITACH2100). EQE was recorded using a Newport Oriel QE-200 (Newport 300 W xenon lamp). All J-V curves were measured using a source meter (Keithley 2420, USA) under AM 1.5 sunlight at an irradiance of 100 mW cm^{-2} provided by a solar simulator (Newport, Oriel Sol3A Class AAA, 94043A). The device area was 0.04 cm^2 . Light intensity was calibrated using a monocrystalline silicon reference cell with a KG5 window (Newport, Oriel 91150). Impedance spectroscopy (IS) was measured by Zennium (Zahner).

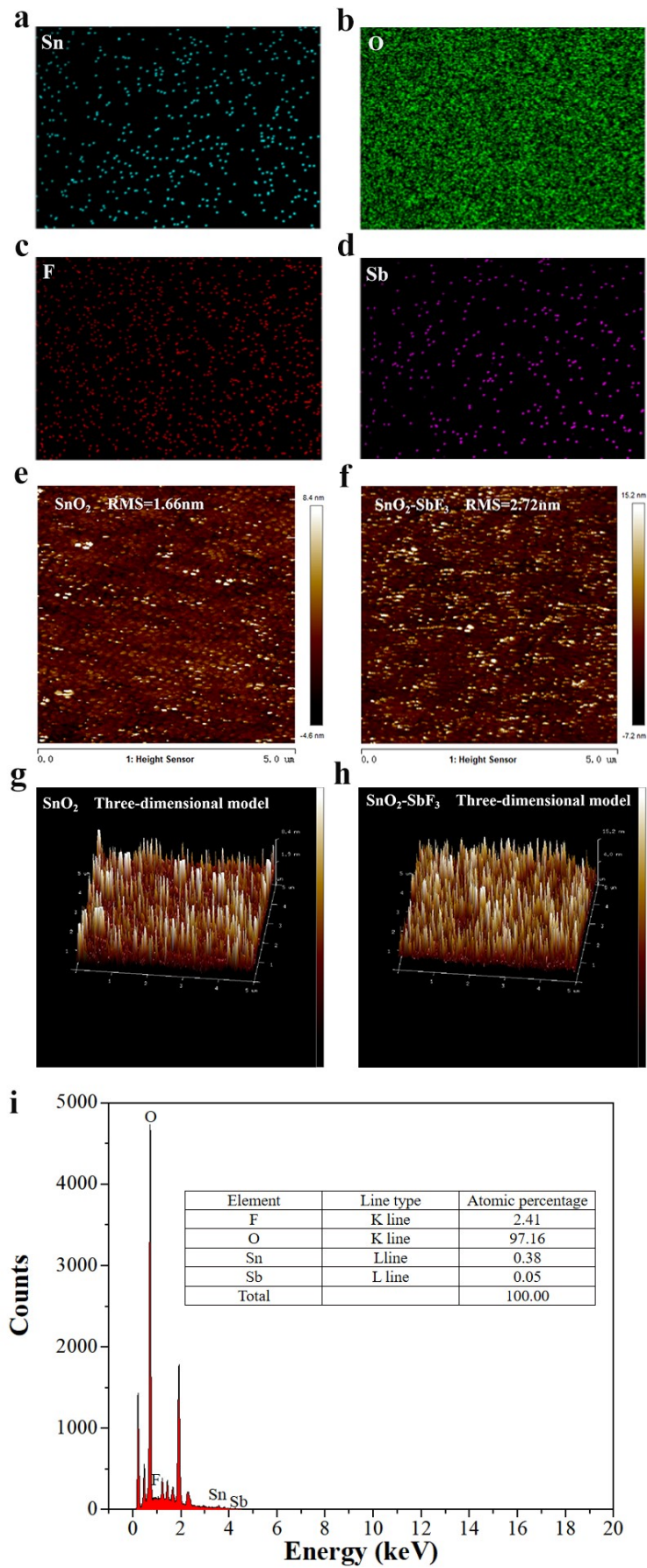


Figure S1. (a)-(d) and (i) EDS mappings of the SnO₂-SbF₃ film on glass, (e)-(h) AFM images of the SnO₂ and SnO₂-SbF₃ films.

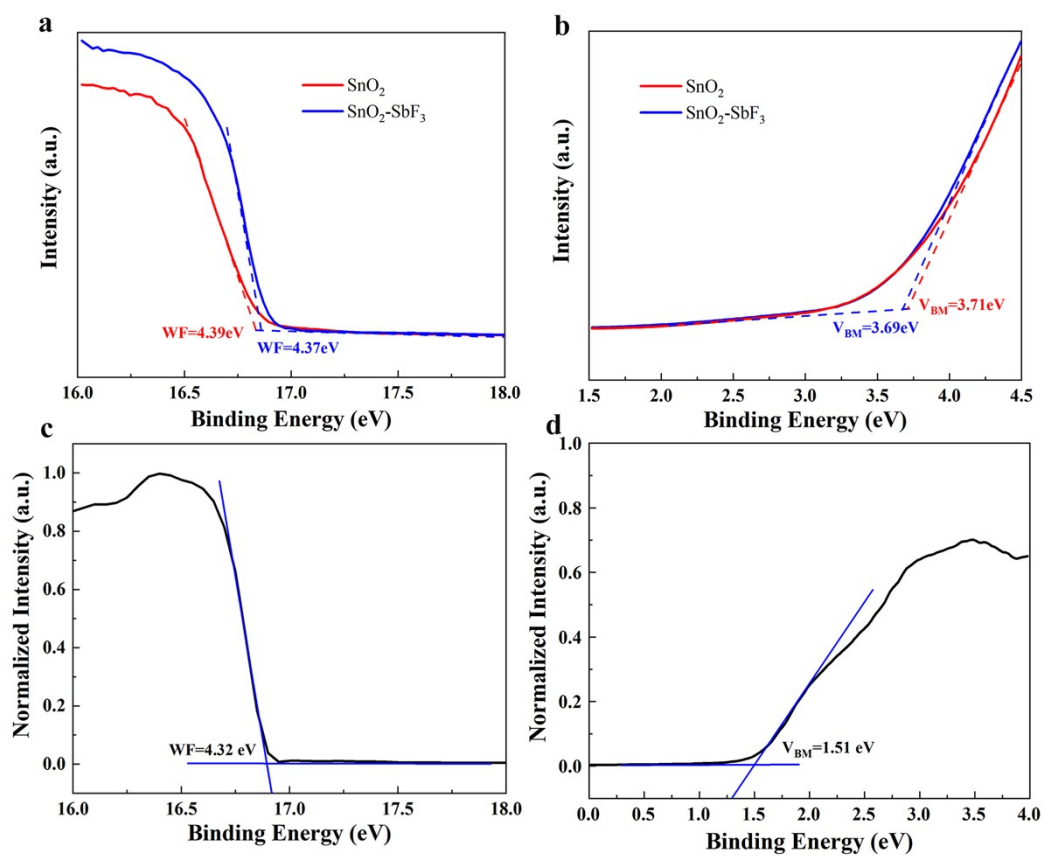


Figure S2. (a) UPS cutoff edge and (b) valence band spectrum of SnO₂, SnO₂-SbF₃. (c) UPS cutoff edge and (d) valence band spectra of the perovskite film.

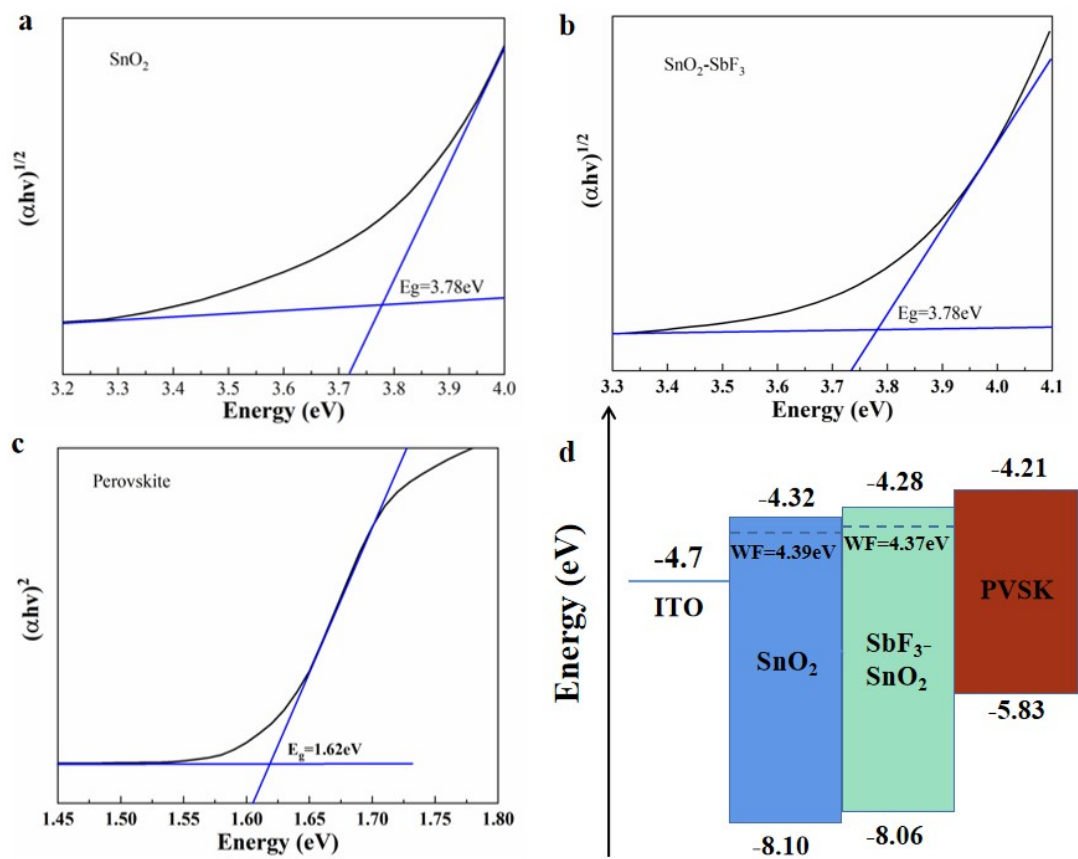


Figure S3. (a)-(c) Bandgap measurement and (d) schematic energy-level diagram.

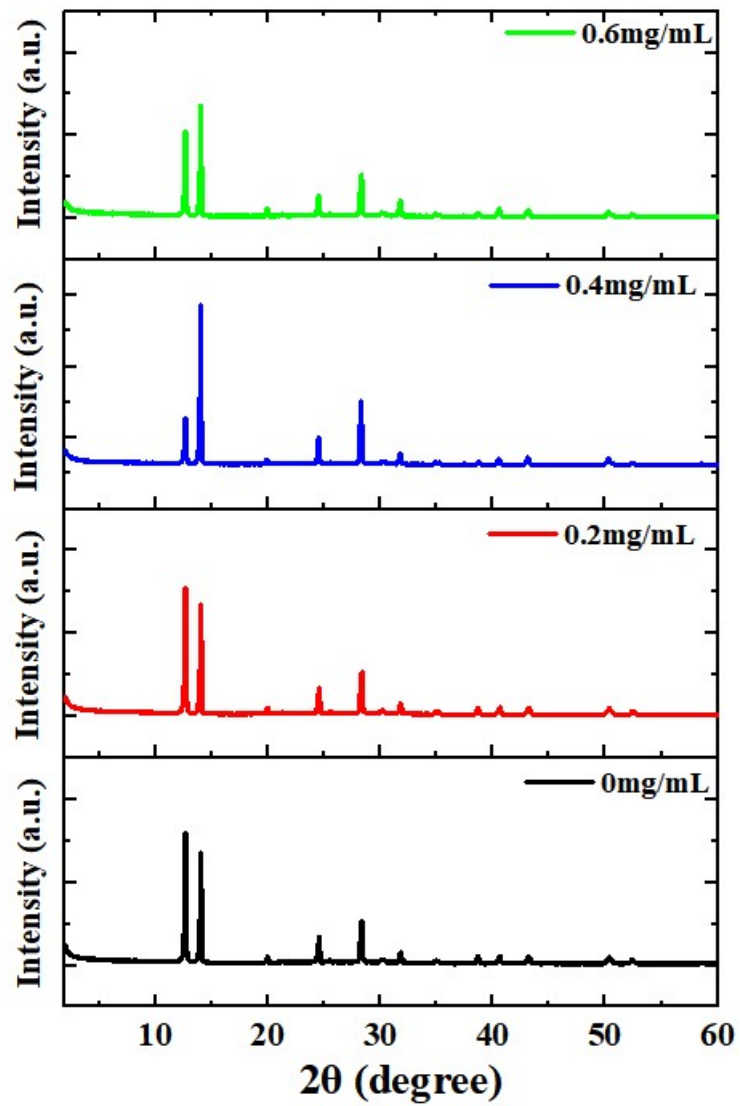


Figure S4. XRD patterns of perovskite films deposited on ETL with different SbF_3 amounts.

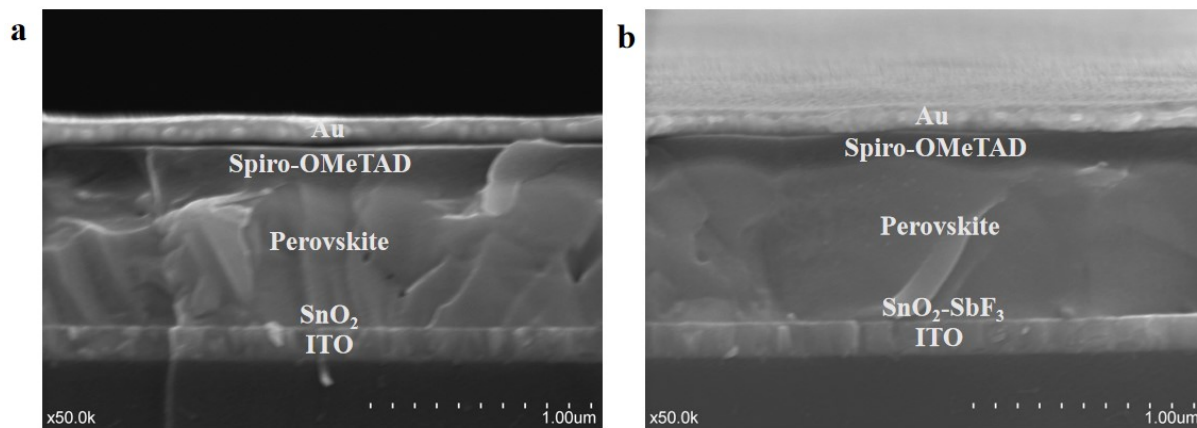


Figure S5. Cross-sectional SEM images of devices.

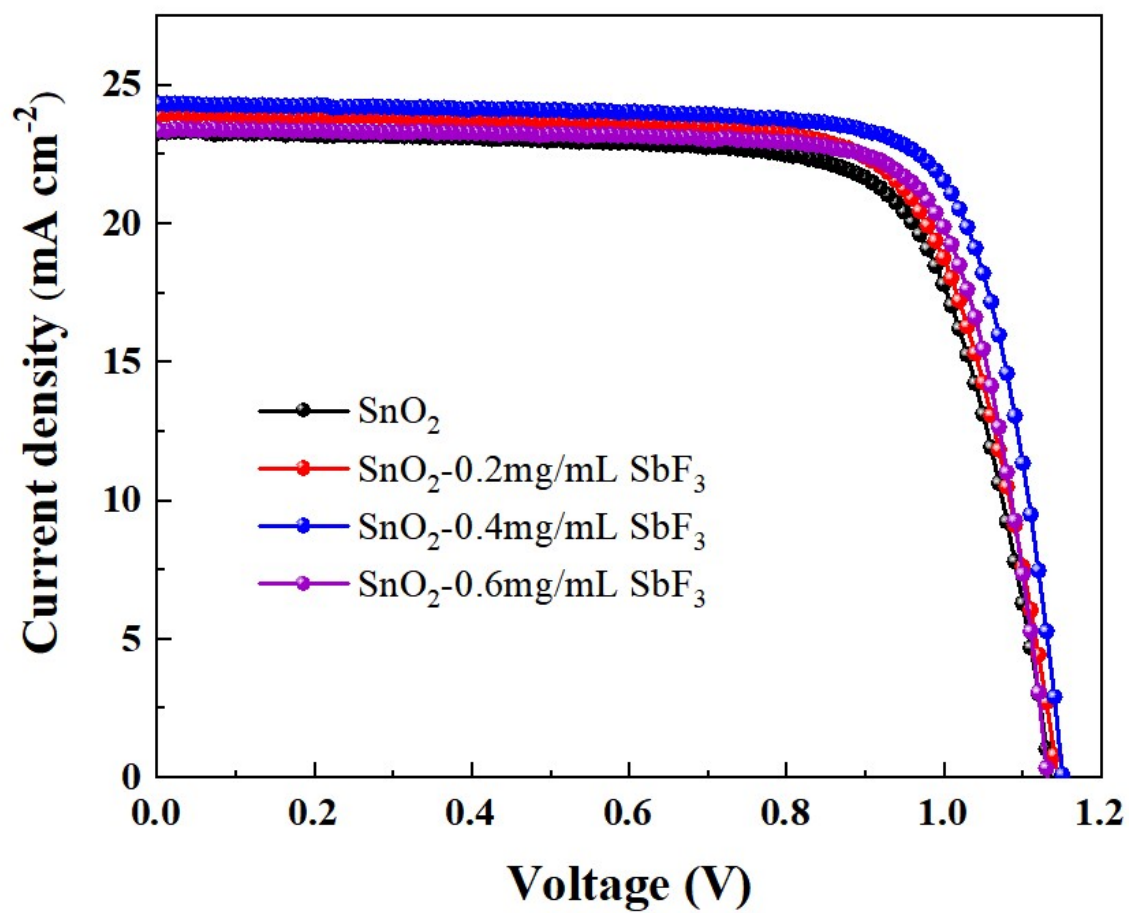


Figure S6. J-V curves of SnO₂-SbF₃ devices with different concentrations of SbF₃ aqueous solution.

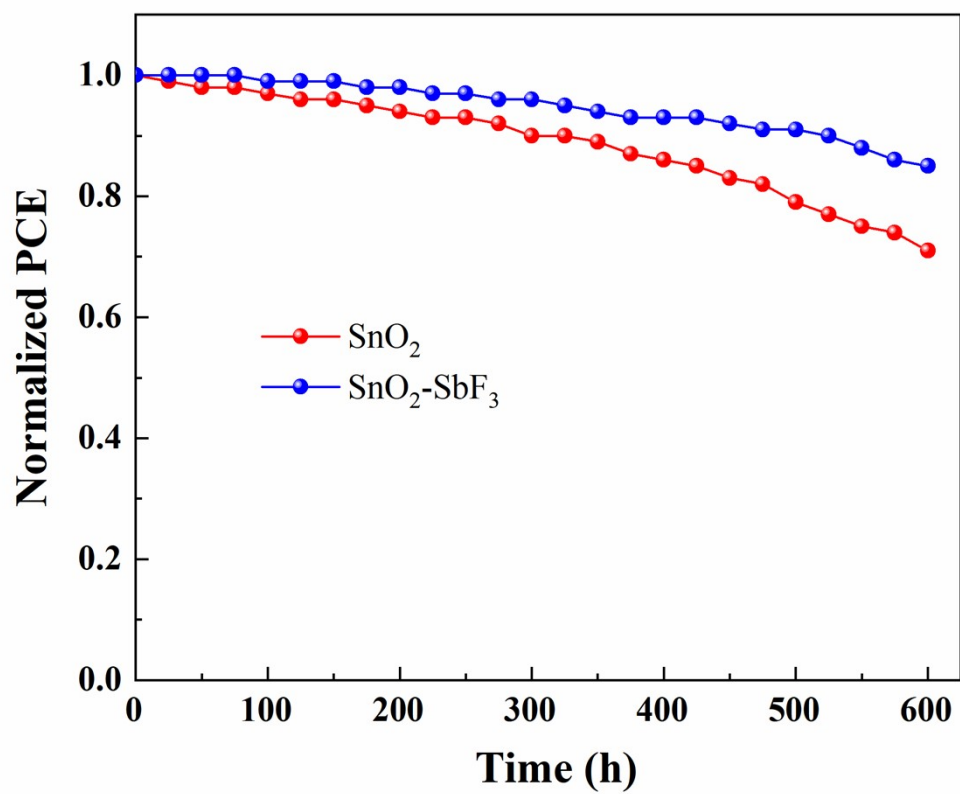


Figure S7. The long-term stability of PSCs based on SnO₂ or SnO₂-SbF₃.

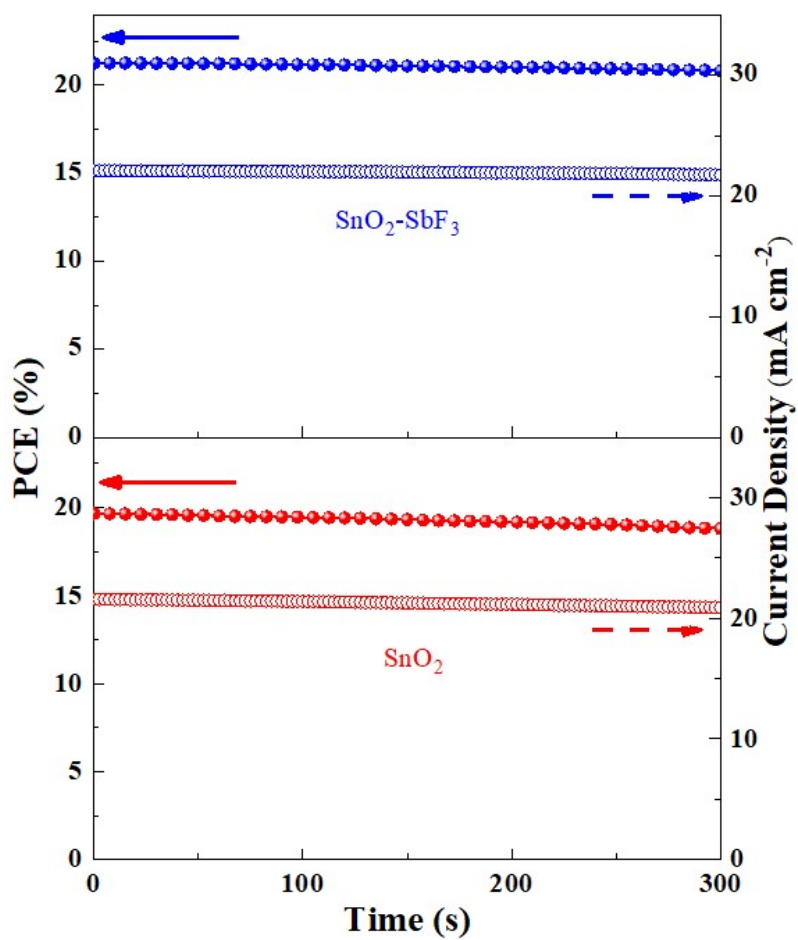


Figure S8. MPP tracking for PSCs under continuous AM 1.5 G illumination (The V_{MPP} of SnO_2 device is 0.918 V, and the V_{MPP} of $\text{SnO}_2\text{-SbF}_3$ device is 0.948 V).

The electron mobility of the ETL was determined by using a space charge finite current (SCLC) model with the ITO/Al/ETL/Al structure (ETL was SnO₂ film or SnO₂-SbF₃ film). Here, we calculate the electron mobility by using the following Equation:^[1]

$$\mu_e = \frac{8JL^3}{9\varepsilon_0\varepsilon_r(V_{app} - V_r - V_{bi})^2}$$

where μ_e , J , L , ε_0 , ε_r , V_{app} , V_r , and V_{bi} are electron mobility, current density, thickness of ETL, , vacuum permittivity, relative dielectric constant of ETL, applied voltage, voltage drop and built-in voltage, respectively. The calculated parameters and electron mobility are listed in Table S1 as follows.

Table S1 The calculated electron mobility of the ETL.

ETL	Mobility [cm ² V ⁻¹ S ⁻¹]	Thickness [nm]
SnO ₂	2.38 × 10 ⁻⁴	32.7
SnO ₂ -SbF ₃	4.35 × 10 ⁻⁴	34.8

The structures composed of ITO/ETL/Au were fabricated to study the conductivity of ETLs. Figure 2b shows the current-voltage (I-V) characteristic curves. We calculated the conductivity (σ) using the following Equation:^[2]

$$\sigma = \frac{Id}{VA}$$

where A is the area and d is the thickness of the ETL. The calculated parameters and conductivity are listed in Table S2 as follows.

Table S2 The calculated electron conductivity of the ETL.

ETL	Slop [I/V]	Thickness [nm]	Conductivity [mScm ⁻¹]
SnO ₂	46.5	32.7	3.80 × 10 ⁻³
SnO ₂ -SbF ₃	59.7	34.8	5.19 × 10 ⁻³

The average recombination lifetime was estimated from the TRPL spectra fitted by a bi-exponential decay function, the equation is as follows:^[3]

$$\tau_{ave} = \frac{\sum A_i \tau_i^2}{\sum A_i \tau_i}$$

where τ_i is decay times and A_i is amplitudes.

Table S3 Parameters for the TRPL spectra of the perovskite films deposited SnO₂ or SnO₂-SbF₃.

Sample	τ_1 [ns]	A ₁	τ_2 [ns]	A ₂	τ_{ave} [ns]
ITO/SnO ₂ /perovskite	77.21	194.03	276.32	152.77	224.17
ITO/SnO ₂ -SbF ₃ /perovskite	67.04	166.43	233.54	143.75	191.98

Table S4 Calculated parameters and trap density (N_t) of the perovskite films deposited on SnO₂ or SnO₂-SbF₃.

Sample	L [nm]	ϵ	V _{TFL} [V]	N _t [$\times 10^{15} \text{cm}^{-3}$]
SnO ₂	720	42.3	0.626	5.65
SnO ₂ -SbF ₃	720	42.3	0.433	3.91

Table S5 EIS parameters of the SnO₂ and SnO₂-SbF₃ devices.

Substrates	R _s [Ω]	R _{tr} [k Ω]	C _{tr} [F]	R _{rec} [k Ω]	C _{rec} [F]
SnO ₂	35.1	54.5	9.416E-10	2904.2	5.119E-8
SnO ₂ -SbF ₃	34.3	45.2	1.078E-9	3492.3	6.289E-8

Table S6 Parameters of the devices with different SbF₃ concentrations.

SnO ₂ -SbF ₃	V _{oc} [V]	J _{sc} [mA/cm ²]	FF(%)	PCE(%)
0mg/mL	1.132	23.42	75.03	19.89
0.2mg/mL	1.144	23.85	75.59	20.62
0.4mg/mL	1.146	24.24	77.10	21.42

0.6mg/mL	1.133	23.51	75.80	20.19
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References

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